

## IV600 (Magazine to Magazine process)



Magazine to Magazine plasma process

### Specifications

Model	IV600
Plasma method	RIE
Electrode structure	For Magazine correspondence electrode structure
RF generator	100-600W
Oscillating frequency	13.56MHz
Control system	LCD touch panel with PLC
Chamber size	(W)230×(D)400×(H)200mm
Chamber material	Aluminum
Reaction gas	O <sub>2</sub> ,Ar
Purge gas	N <sub>2</sub> or Dry air
Flow meter	Mass flow control 2 line
Vacuum pump	1000L/min
Gas system	2 line (Reaction gas) , 1 line (Purge gas)
External dimension	(W)1,000×(D)900×(H)970mm
Power supply	AC200/220/380V 3 phase 10A